ACS APPLIED MATERIALS & INTERFACES

Ultraviolet Electroluminescence from ZnS@ZnO Core-Shell Nanowires/p-GaN Introduced by Exciton Localization

Xuan Fang,[†] Zhipeng Wei,^{*,†} Yahui Yang,[§] Rui Chen,^{*,§} Yongfeng Li,[‡] Jilong Tang,[†] Dan Fang,[†] Huimin Jia,[†] Dengkui Wang,[†] Jie Fan,[†] Xiaohui Ma,[†] Bin Yao,[‡] and Xiaohua Wang[†]

[†]State Key Laboratory of High Power Semiconductor Lasers, School of Science, Changchun University of Science and Technology, 7089 Wei-Xing Road, Changchun 130022, P. R. China

[§]Department of Electrical and Electronic Engineering, South University of Science and Technology of China, Shenzhen, Guangdong 518055, P. R. China

[‡]Key Laboratory of Physics and Technology for Advanced Batteries, Ministry of Education, College of Physics, JilinUniversity, Changchun 130012, P. R. China

Supporting Information

ABSTRACT: We investigate the electroluminescence (EL) from light emitting diodes (LEDs) of ZnO nanowires/p-GaN structure and ZnS@ZnO core-shell nanowires/p-GaN structure. With the increase of forward bias, the emission peak of ZnO nanowires/p-GaN structure heterojunction shows a blue-shift, while the ZnS@ZnO core-shell nanowires/p-GaN structure demonstrates a changing EL emission; the ultraviolet (UV) emission at 378 nm can be observed. This discrepancy is related to the localized states introduced by ZnS particles, which results in a different carrier recombination process near the interfaces of the heterojunction. The localized states capture the carriers in ZnO nanowires and convert them to localized excitons under high forward bias. A strong UV emission due to localized excitons can be observed. Our results indicated that utilizing localized excitons should be a new route toward ZnO-based ultraviolet LEDs with high efficiency.



KEYWORDS: ZnO, core-shell nanowires, localized excitons, electroluminescence, gan, heterojunction

1. INTRODUCTION

Owing to its wide band gap (3.37 eV) and high exciton binding energy (60 meV), ZnO has been considered to be the most important optoelectronic semiconductor material, ¹⁻⁴ especially for the next generation solid-state lighting sources. ⁵⁻⁸ However, the realization of stable and reproducible p-ZnO is still challenging, which hinders the further development of ZnO-based homogeneous junction devices. ^{9,10} Therefore, the ZnO-based heterojunction has only gradually become an important device structure. ^{11,12}

Because of the similarity of crystallographic and electronic properties between ZnO and GaN, the ZnO/p-GaN heterojunction is employed as one of the most effective ways to realize blue/ultraviolet (UV) electroluminescence (EL) emission.^{13–16} However, the recombination of electrons and holes near the interface, due to higher concentration and mobility of electrons in ZnO than that of holes in p-GaN, results in the EL emission being out of the UV region (in the blue region).¹⁶ Therefore, developing a structure of ZnO heterojunction which can achieve the recombination of electrons and holes at ZnO to realize UV emission has received much attention.

Currently, various ZnO/p-GaN heterojunction structures have been proposed, and the method of inserting layers between ZnO and GaN are recognized as an effective way to control the carrier transport and the emission wavelengths.^{12,17,18}

However, the intermediate layer has limited the carrier transportation and leads to low light emitting efficiency. Because of the gain of advanced physical and chemical properties, the integration of ZnO nanostructures (nanowires or quantum dots) with GaN could be a feasible approach to obtain light-emitting diodes (LEDs) with high performance.^{13,15,19,20} Several kinds of low-dimensional nanostructures have been studied extensively; however, it is known that the optoelectronic properties of these devices are greatly influenced by the surface properties of ZnO nanostructures.^{13,19–23} Thus, various approaches such as quantum dots sensitization and the introduction of localized surface plasmon or localized excitons have been adopted to optimize the performance of ZnO nanostructures.^{21–26}

Herein, we propose the ZnS@ZnO core-shell nanowires/ p-GaN structure heterojunctions. The strategy of using a coreshell structure not only allows the efficient use of individual ZnO nanowires but also enhances the charge carrier recombination by localized excitons.^{21,22,27–29} It is known that ZnS@ ZnO core-shell structures exhibit more excellent optoelectronic properties. Modified by a ZnS coating, surface states of ZnO nanowires can be effectively suppressed. Additionally, the

Received:September 22, 2015Accepted:December 28, 2015Published:December 28, 2015

introduced localized excitons could greatly improve luminescence properties of ZnO nanowires, which play a significant role for UV emission.^{27,30,31} In this paper, we shall compare ZnO nanowires/p-GaN structure and ZnO/ZnS core-shell nanowires/p-GaN structure heterojunctions. The morphology and optical properties of the ZnO nanowire with and without ZnS coating have been investigated. For the EL measurement, carrier transport process and the physical mechanism shall be discussed in detail. Finally, pure UV EL located at 378 nm has been achieved, and it was ascribed to the excitons localization. Our approach provides an alternative way to realize the UV emission from ZnO nanomaterials, which is simple, effective, and accessible for other material systems.

2. EXPERIMENTAL SECTION

Synthesis of ZnO Nanowires/p-GaN Structure. First, 0.01 M zinc acetate and 0.01 M hexamethylenetetramine were dissolved in aqueous solution, then the mixed solution was transferred to a Teflon-lined stainless autoclave of 50 mL capacity. Second, p-GaN was put into the solution. The tank was held in an electric oven at 95 °C for 8 h. After the reaction, the sample was washed by deionized water and dried in air at 60 °C for several hours.³²

Synthesis of ZnS@ZnO Core—Shell Nanowires/p-GaN Structure. The ZnS@ZnO core—shell nanowires/p-GaN sample was synthesized by chemical bath deposition (CBD). The as-grown ZnO nanowires/p-GaN sample was immersed in 0.16 mol/L sodium sulfide and 0.16 mol/L zinc nitrate mixed solution at a temperature of 60 °C for 2 h, respectively. After the reaction, the sample was also washed by deionized water and dried in air at 60 °C for several hours.

Preparation ZnO Heterojunction. ZnO nanowires and ZnS@ ZnO core-shell nanowires were used as n-type materials, while the p-GaN was used as p-type material. To Ohmic contacts, indium tin oxide (ITO) and Ni-Au/In electrode were sputtered on ZnO and GaN, respectively.

Measurements Conditions. A Hitachis-4800 field emission scanning electron microscope (FESEM) and energy-dispersive X-ray spectroscopy (EDS, GENE SIS 2000 XMS 60S, EDAX, Inc.) attached to the SEM and X-ray diffraction (XRD) were used to characterize the morphology and chemical composition of the samples. A He–Cd laser with line of 325 nm was used as the excitation source to perform PL measurements. EL measurements were performed by a fluorescence meter (F4500 Hitachi). The current–voltage (I-V) curve was measured by a semiconductor parameter analyzer with a sensitivity of 0.1 pA.

3. RESULTS AND DISCUSSION

Figure 1a and Figure 1b show the morphology characterization of ZnO and ZnS@ZnO core-shell nanowires, respectively. It can be seen that both nanowires samples were of the welldefined hexagonal shape. The insets of Figure 1a and Figure 1b show that the diameter of nanowires was estimated to be about 100 nm. Because of the growth of outer ZnS layer, the surface of the core-shell nanowires became rough, and the diameter slightly increased. In addition, ZnS particles with a diameter of about 5 nm can be clearly observed in the TEM images, as shown in the inset of Figure 1c. On the basis of our previous research,²² it is noted that the localized states can form at the interface of ZnO nanowires and ZnS particles, which could prevent excitons generated in ZnO diffusing to nonradiative recombination centers.^{21,33} From our photoluminescence (PL) measurement, ZnS@ZnO nanowires exhibited an enhanced UV emission located at 377 nm caused by localized excitons, which was about 4 times higher than the ZnO nanowires (as shown in Figure 1c). Meanwhile, the intensity of defect emission was depressed because of surface passivation.³⁴



Figure 1. (a,b) SEM images of ZnO and ZnS@ZnO core–shell nanowires; (c) PL spectrum of ZnO (black curve) and ZnS@ZnO core–shell nanowires (red curve), the inset is TEM images of ZnO and ZnS@ZnO core–shell nanowires.

Figure 2a and Figure 2b show the EL spectra of the devices under forward bias from 1.5 to 10 V, while the insets are the schematic diagrams and relationship between the integrated EL intensity and voltage of two heterojunctions. For ZnO nanowires/p-GaN, the emission peak at about 430 nm was observed. Similar emission has been detected for ZnS@ZnO core-shell nanowires/p-GaN at lower forward bias. However, at higher forward bias, besides the emission at 430 nm, a new emission at 378 nm appeared. Voltage-dependence of integrated EL intensity of the samples are shown in the insets of Figure 2a and Figure 2b. Increasing the forward bias resulted in an increase of integrated EL intensity of the two devices between 350 and 700 nm. However, the increasing trends of integrated EL intensity were still differences, especially at higher forward bias. In addition, the two structures exhibited different I-V curves as shown in Figure S1. Therefore, we speculated that the EL emission mechanism might be different, especially under higher voltage, and localized excitons caused by ZnS particles might be the origin of the unusual EL emission.

To investigate the emission mechanism of the two structures, EL spectra have been analyzed in detail. The EL spectra can be divided into two parts: Part I (voltage from 1.5 to 4 V) and Part II (voltage from 9 to 10 V). First, we focused on the Part I EL spectra as shown in Figure 3 and Figure 4. Figure 3a shows the EL spectra of ZnO nanowires/p-GaN structure under lower forward bias. With the increase of voltage, a clear blue-shift of the emission from 448 to 432 nm was observed. Moreover, the full width at half-maximum (fwhm) of the peak became narrower. From the band alignment of ZnO/GaN, it is known that the energy barrier $\Delta E_{\rm C}$ for electrons is around 0.15 eV, ^{13,35} while the energy barrier $\Delta E_{\rm V}$ for holes is around 0.13 eV.^{13,35} Therefore, electrons and holes will recombine in GaN, and the EL emission originated from GaN can be observed.^{16,36} As plotted in Figure 3b, the EL spectra could be well-fitted by two individual Gaussian peaks, which resulted in P1 emission at 430 nm and P₂ emission at 460 nm. The peaks were attributed to the transitions from donor level E_D in ZnO to the acceptor



Figure 2. (a) EL spectra of ZnO nanowires/p-GaN heterojunction; (b) EL spectra of ZnS@ZnO core-shell nanowires/p-GaN heterojunction. The insets are schematic diagrams and show the relationship between the integrated EL intensity and voltage of two heterojunctions.



Figure 3. (a) EL spectra of ZnO nanowires/p-GaN heterojunction, the voltage range is 1.5 to 3.0 V; (b) Gaussian fitting results of ZnO nanowires/p-GaN heterojunction under 1.5, 2.4, and 3.0 V; (c) relationship between the ratio of EL intensity and voltage of ZnO nanowires/p-GaN heterojunction.



Research Article

Figure 4. (a) EL spectra of ZnS@ZnO core-shell nanowires/p-GaN Heterojunction, the voltage range is 1.5 to 3.0 V; (b) Gaussian fitting results of ZnS@ZnO core-shell nanowires/p-GaN Heterojunction under 1.5, 2.4, and 3.0 V; (c) Relationship between the ratio of EL intensity and voltage of ZnS@ZnO core-shell nanowires/p-GaN Heterojunction.

level E_A in GaN (430 nm) and defect emission in GaN (460 nm) based on the previous reports.^{13,16,19} With the increase of voltage, more and more electrons transferred into GaN, and the intensity of P_1 and P_2 emissions increased. However, the intensity of P_2 emission increases slowly because the saturation of defect levels, and thus the ratio of P_1/P_2 increased gradually. This means electrons in ZnO that transferred into the acceptor level of GaN was dominant, which could also reflect the trend of transitions of electrons as shown in Figure 3c.

For ZnS@ZnO core-shell nanowires/p-GaN, besides a weaker intensity, the shift of peak position and the change of fwhm were almost the same as ZnO nanowires/p-GaN structure (shown in Figure 4a and inset). The EL emission could also be divided into P_1 emission and P_2 emission peaks by the Gaussian analyses, and the ratio of P_1/P_2 increased as well (Figure 4b and Figure 4c). Therefore, for the two structures under low forward bias, it is concluded that the carriers' recombination mechanisms are the same, in other words, electrons from ZnO transferred and recombined with holes in GaN.^{16,36} However, due to the existence of localized states in the $\mathrm{ZnO}/$ ZnS interface, parts of the generated electrons would convert into localized excitons. So under the same forward bias, the free electrons in ZnS@ZnO core-shell nanowires would be less than ZnO nanowires, which means that the recombination of electrons and holes of p-GaN was suppressed.

For Part II EL spectra, Figure 5a and Figure 5b present the EL emission of the samples under forward bias of 10 V. For the ZnO nanowires/p-GaN structure, the EL emission located at the same position around 430 nm. For the ZnS@ZnO core-shell nanowires/p-GaN structure, UV emission at 378 nm has been observed. As shown in Figure S2, emission peak P_3 (402 nm) and P_4 (378 nm) can be deduced with Gaussian



Figure 5. (a) EL spectra of ZnO nanowires/p-GaN heterojunction under 10.0 V; (b) EL spectra of ZnS@ZnO core-shell nanowires/p-GaN heterojunction under 10.0 V; (c) schematic diagrams of carrier recombination and energy band schematic diagram of ZnO nanowires/p-GaN heterojunction; (d) schematic diagrams of carrier recombination and energy band schematic diagram of ZnS@ZnO core-shell nanowires/p-GaN heterojunction.

analyses. P₃ emission was caused by the transitions from the conduction band edge of ZnO to the acceptor level of GaN,^{13,19} while the P₄ emission should be the EL emission from ZnO. It can be seen that the ratio of P₃/P₁ of the two structures was different. For ZnO nanowires/p-GaN structure, this ratio increase indicated that the recombination zone moved from the GaN to the interface of heterojunction. But for ZnS@ ZnO core-shell nanowires/p-GaN structure, the increase of P₃/P₁ was not obvious. On the basis of the existence of P₄ emission, we concluded that the recombination zone kept moving from the interface to the ZnO nanorods.³⁵

In Figure 5c and Figure 5d, the schematic diagrams of carrier recombination and energy band schematic diagrams were plotted to explain the carrier transition processes. For the ZnO nanowires/p-GaN structure, the electrons possess a high probability to transit from the side of ZnO to p-GaN, which results in recombination and EL emission of GaN. This process depends on the forward bias. Under higher forward bias, more electrons would be transported into GaN, the blue shift phenomenon and a competitive relationship of P1, P2, and P3 could be observed (from the ratio of P_1/P_2 and P_3/P_1). For the ZnS@ZnO core-shell nanowires/p-GaN structure, localized states introduced by ZnS coating would confine parts of free electrons generated in ZnO nanowires. The other electrons in ZnS@ZnO core-shell nanowires could still transit into GaN, and P1, P2, and P3 emissions still existed. In previously works, it was shown that ZnO had higher emission efficiently in localized states.^{22,37} Under high forward bias, such as 9 and 10 V, the holes in GaN could transfer into the localized states of ZnO because of the high internal electric field and recombine with the captured electrons, which leads to the P4 emission located at 378 nm. All the processes are presented in Figure 5. Utilizing localized excitons, we have achieved the pure UV emission from ZnO/GaN heterojunction.

4. CONCLUSIONS

We have synthesized ZnO and ZnS@ZnO core-shell nanowires. The latter had perfect crystal quality and enhanced UV emission because of localized excitions introduced by ZnS. ZnO/GaN heterojunction LEDs based on ZnO nanowires/ p-GaN and ZnS@ZnO core-shell nanowires/p-GaN were designed and fabricated. A highly efficient LED with an UV EL emission peak of 378 nm has been obtained. Analysis of EL spectra and band diagram indicated that the captured electrons and holes caused by localized states can form localized excitons, which should account for the realization of UV EL emission. Our investigation could lead to another high performance emitting device.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsami.5b08961.

Current-voltage characteristic of two heterojunctions; additional EL spectra (PDF)

AUTHOR INFORMATION

Corresponding Authors

*E-mail: zpweicust@126.com.

*E-mail: chen.r@sustc.edu.cn.

Notes

The authors declare no competing financial interest.

ACKNOWLEDGMENTS

This work is supported by the National Natural Science Foundation of China (61204065, 61205193, 61307045, 61404009, 61474010, 61574022, 61504012, 11404219, 11404161, 11574130 and 11204224), the Developing Project

of Science and Technology of Jilin Province (20130101026JC), R. C. acknowledges the national 1000 plan for young talents, the startup fund and the fundamental research grant at SUSTC with Grant No. FRG-SUSTC1501A-43.

REFERENCES

(1) Huang, M. H.; Mao, S.; Feick, H.; Yan, H. Q.; Wu, Y. Y.; Kind, H.; Weber, E.; Russo, R.; Yang, P. D. Room-Temperature Ultraviolet Nanowire Nanolasers. *Science* **2001**, *292*, 1897–1899.

(2) Ng, H. T.; Han, J.; Yamada, T.; Nguyen, P.; Chen, Y. P.; Meyyappan, M. Single Crystal Nanowire Vertical Surround-Gate Field-Effect Transistor. *Nano Lett.* **2004**, *4*, 1247–1252.

(3) Wang, Z. L.; Song, J. Piezoelectric Nanogenerators Based on Zinc Oxide Nanowire Arrays. *Science* **2006**, *312*, 242.

(4) Wang, S. H.; Lin, L.; Wang, Z. L. Nanoscale Triboelectric-Effect-Enabled Energy Conversion for Sustainably Powering Portable Electronics. *Nano Lett.* **2012**, *12*, 6339–6346.

(5) Chu, S.; Wang, G. P.; Zhou, W. H.; Lin, Y. Q.; Chernyak, L.; Zhao, J. Z.; Kong, J. Y.; Li, L.; Ren, J. J.; Liu, J. L. Electrically Pumped Waveguide Lasing From ZnO Nanowires. *Nat. Nanotechnol.* **2010**, *6*, 506–510.

(6) Leong, E. S. P.; Yu, S. F. UV Random Lasing Action in p-SiC(4H)/i-ZnO-SiO₂ Nanocomposite/n-ZnO:Al Heterojunction Diodes. *Adv. Mater.* **2006**, *18*, 1685–1688.

(7) Chen, R.; Ye, Q. L.; He, T. C.; Wu, T.; Sun, H. D. Uniaxial Tensile Strain and Exciton–Phonon Coupling in Bent ZnO Nanowires. *Appl. Phys. Lett.* **2011**, *98*, 241916.

(8) Li, Y. F.; Yin, W. J.; Deng, R.; Chen, R.; Chen, J.; Yan, Q. Y.; Yao, B.; Sun, H. D.; Wei, S. H.; Wu, T. Realizing a SnO_2 -Based Ultraviolet Light-Emitting Diode via Breaking the Dipole-Forbidden Rule. *NPG Asia Mater.* **2012**, *4*, E30.

(9) Fang, X.; Li, J. H.; Zhao, D. X.; Shen, D. Z.; Li, B. H.; Wang, X. H. Phosphorus-Doped p-Type ZnO Nanorods and ZnO Nanorod p-n Homojunction LED Fabricated by Hydrothermal Method. *J. Phys. Chem.* C **2009**, *113*, 21208–21212.

(10) Yang, X.; Shan, C. X.; Jiang, M. M.; Qin, J. M.; Hu, G. C.; Wang, S. P.; Ma, H. A.; Jia, X. P.; Shen, D. Z. Intense Electroluminescence from ZnO Nanowires. *J. Mater. Chem. C* **2015**, *3*, 5292–5296.

(11) Ding, M.; Zhao, D. X.; Yao, B.; Li, Z. P.; Xu, X. J. Ultraviolet Photodetector Based on Heterojunction of n-ZnO Microwire/p-GaN Film. *RSC Adv.* **2015**, *5*, 908–912.

(12) Xu, Y. T.; Xu, L.; Dai, J.; Ma, Y.; Chu, X. W.; Zhang, Y. T.; Du, G. T.; Zhang, B. L.; Yin, J. Z. Ultraviolet-Enhanced Light Emitting Diode Employing Individual ZnO Microwire with SiO₂ Barrier Layers. *Appl. Phys. Lett.* **2015**, *106*, 212105.

(13) Guo, Z.; Li, H. W.; Zhou, L. Q.; Zhao, D. X.; Wu, Y. H.; Zhang, Z. Q.; Zhang, W.; Li, C. Y.; Yao, J. Large-Scale Horizontally Aligned ZnO Microrod Arrays with Controlled Orientation, Periodic Distribution as Building Blocks for Chip-in Piezo-Phototronic LEDs. *Small* **2015**, *11*, 438–445.

(14) Zhu, H.; Shan, C. X.; Zhang, J. Y.; Zhang, Z. Z.; Li, B. H.; Zhao, D. X.; Yao, B.; Shen, D. Z.; Fan, X. W.; Tang, Z. K.; Hou, X. H.; Choy, K. L. Low-Threshold Electrically Pumped Random Lasers. *Adv. Mater.* **2010**, *22*, 1–5.

(15) Shi, Z. F.; Zhang, Y. T.; Cui, X. J.; Wu, B.; Zhuang, S. W.; Yang, F.; Yang, X. T.; Zhang, B. L.; Du, G. T. Improvement of Electroluminescence Performance by Integration of ZnO Nanowires and Single-Crystalline Films on ZnO/GaN Heterojunction. *Appl. Phys. Lett.* **2014**, *104*, 131109.

(16) Alivov, Ya. I.; Van Nostrand, J. E.; Look, D. C.; Chukichev, M. V.; Ataev, B. M. Observation of 430 nm Electroluminescence from ZnO/GaN Heterojunction Light Emitting Diodes. *Appl. Phys. Lett.* **2003**, *83*, 14.

(17) Sun, J. W.; Lu, Y. M.; Liu, Y. C.; Shen, D. Z.; Zhang, Z. Z.; Li, B. H.; Zhang, J. Y.; Yao, B.; Zhao, D. X.; Fan, X. W. Excitonic Electroluminescence from ZnO-Based Heterojunction Light Emitting Diodes. J. Phys. D: Appl. Phys. **2008**, 41, 155103.

(18) Leong, E. S. P.; Yu, S. F.; Lau, S. P. Directional Edge-Emitting UV Random Laser Diodes. *Appl. Phys. Lett.* **2006**, *89*, 221109.

(19) Wang, D. K.; Wang, F.; Wang, Y. P.; Fan, Y.; Zhao, B.; Zhao, D. X. Interfacial Emission Adjustment in ZnO Quantum Dots/p-GaN Heterojunction Light-Emitting Diodes. *J. Phys. Chem. C* 2015, *119*, 2798–2803.

(20) Zhang, C.; Marvinney, E. C.; Xu, H. Y.; Liu, W. Z.; Wang, C. L.; Zhang, L. X.; Wang, J. N.; Ma, J. G.; Liu, Y. C. Enhanced Waveguidetype Ultraviolet Electroluminescence from ZnO/MgZnO Core/Shell Nanorod Aarray Light-Emitting Diodes via Coupling with Ag Nanoparticles Localized Surface Plasmons. *Nanoscale* **2015**, *7*, 1073–1080.

(21) Chen, R.; Ye, Q. L.; He, T. C.; Ta, V. D.; Ying, Y. J.; Tay, Y. Y.; Wu, T.; Sun, H. D. Exciton Localization and Optical Properties Improvement in Nanocrystal-Embedded ZnO Core–Shell Nanowires. *Nano Lett.* **2013**, *13*, 734–739.

(22) Fang, X.; Wei, Z. P.; Chen, R.; Tang, J. L.; Zhao, H. F.; Zhang, L. G.; Zhao, D. X.; Fang, D.; Li, J. H.; Fang, F.; Chu, X. Y.; Wang, X. H. Influence of Exciton Localization on the Emission and Ultraviolet Photoresponse of ZnO/ZnS Core–Shell Nanowires. *ACS Appl. Mater. Interfaces* **2015**, *7*, 10331–10336.

(23) Kim, J.; Dutta, A.; Memarzadeh, B.; Kildishev, A. V.; Mosallaei, H.; Boltasseva, A. Zinc Oxide Based Plasmonic Multilayer Resonator: Localized and Gap Surface Plasmon in the Infrared. *ACS Photonics* **2015**, *2*, 1224–1230.

(24) Patrik, Š.; Saulius, M.; Kestutis, J.; Kazumasa, H.; Hideto, M.; Bernard, G. Excitation-Dependent Carrier Dynamics in Al-Rich AlGaN Layers and Multiple Quantum Wells. *Phys. Status Solidi B* **2015**, 252, 1043–1049.

(25) Grinblat, G.; Borrero-Gonzalez, L. J. B.; Nunes, L. A. O.; Tirado, M.; Comedi, D. Enhanced Optical Properties and (Zn, Mg) Interdiffusion in Vapour Transport Grown ZnO/MgO Core/Shell Nanowires. *Nanotechnology* **2014**, *25*, 035705.

(26) Kim, N. Y.; Hong, S. H.; Kang, J. W.; Myoung, N.; Yim, S. Y.; Jung, S.; Lee, K.; Tue, C. W.; Park, S. J. Localized Surface Plasmon-Enhanced Green Quantum Dot Light-Emitting Diodes using Gold Nanoparticles. *RSC Adv.* **2015**, *5*, 19624–19629.

(27) Rai, C. S.; Wang, K.; Ding, Y.; Marmon, J. K.; Bhatt, M.; Zhang, Y.; Zhou, W. L.; Wang, Z. L. Piezo-Phototronic Effect Enhanced UV/ Visible Photodetector Based on Fully Wide Band Gap Type-II ZnO/ ZnS Core/Shell Nanowire Array. *ACS Nano* **2015**, *9*, 6419–6427.

(28) Treu, J. L.; Bormann, M.; Schmeiduch, H.; Döblinger, M.; Morkötter, S.; Matich, S.; Wiecha, P.; Saller, K.; Mayer, B.; Bichler, M.; Amann, M. C.; Finley, J. J.; Abstreiter, G.; Koblmüller, G. Enhanced Luminescence Properties of InAs–InAsP Core–Shell Nanowires. *Nano Lett.* **2013**, *13*, 6070–6077.

(29) Xing, G. Z.; Wang, D. D.; Cheng, C. J.; He, M.; Li, S.; Wu, T. Emergent Ferromagnetism in ZnO/Al2O3 Core-Shell nanowires: Towards Oxide Spinterfaces. *Appl. Phys. Lett.* **2013**, *103*, 022402.

(30) Panigrahi, S.; Sarkar, S.; Basak, D. Metal-Free Doping Process to Enhance the Conductivity of Zinc Oxide Nanorods Retaining the Transparency. *ACS Appl. Mater. Interfaces* **2012**, *4*, 2709–2716.

(31) Wang, K.; Chen, J. J.; Zeng, Z. M.; Tarr, J.; Zhou, W. L. Synthesis and Photovoltaic Effect of Vertically Aligned ZnO/ZnS Core/Shell Nanowire Arrays. *Appl. Phys. Lett.* **2010**, *96*, 123105.

(32) Fang, X.; Wang, X. H.; Zhao, D. X.; Zhao, H. F.; Fang, F.; Wei, Z. P.; Li, J. H.; Chu, X. Y.; Wang, F.; Wang, D. D.; Yan, Y. S. Electroluminescence of ZnO Nanorods/ZnMgO Films/p-SiC Structure Heterojunction LED. *Phys. E (Amsterdam, Neth.)* **2014**, *59*, 93–97.

(33) Satake, A.; Masumoto, Y. Localized Exciton and its Stimulated Emission in Surface Mode from Single-Layer $In_xGa_{1.x}N$. *Phys. Rev. B: Condens. Matter Mater. Phys.* **1998**, 57, R2041–R2044.

(34) Wang, B.; Wei, Z. P.; Li, M.; Liu, G. J.; Zou, Y. G.; Xing, G. Z.; Tan, T. T.; Li, S.; Chu, X. Y.; Fang, F.; Fang, X.; Li, J. H.; Wang, X. H.; Ma, X. H. Tailoring the Photoluminescence Characteristics of p-Type GaSb: The Role of Surface Chemical Passivation. *Chem. Phys. Lett.* **2013**, 556, 182–187.

(35) Fang, F.; Zhao, D. X.; Li, B. H.; Zhang, Z. Z.; Shen, D. Z. Hydrogen Effects on the Electroluminescence of n-ZnO Nanorod/p-GaN Film Heterojunction Light-Emitting Diodes. *Phys. Chem. Chem. Phys.* **2010**, *12*, 6759–6762.

(36) Jiao, S. J.; Lu, Y. M.; Shen, D. Z.; Zhang, Z. Z.; Li, B. H.; Zhang, J. Y.; Yao, B.; Liu, Y. C.; Fan, X. W. Ultraviolet Electroluminescence of ZnO Based Heterojunction Light Emitting Diode. *Phys. Status Solidi C* **2006**, *3*, 972–975.

(37) Iwamura, M.; Akizuki, N.; Miyauchi, Y.; Mouri, S.; Shaver, J.; Gao, Z. H.; Cognet, L.; Lounis, B.; Matsuda, K. Nonlinear Photoluminescence Spectroscopy of Carbon Nanotubes with Localized Exciton States. *ACS Nano* **2014**, *8*, 11254–11260.